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Bib Data Sheet

CONFIRMATION NO. 4946

SERIAL NUMBER 10/660,151	FILING DATE 09/11/2003  RULE	CLASS 438	GROUP ART UNIT 2812	ATTORNEY DOCKET NO. 004994 ALRT/ETCH/SILICON
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\*\* CONTINUING DATA \*\*\*\*\*  
 This appln claims benefit of 60/444,340 01/31/2003

\*\* FOREIGN APPLICATIONS \*\*\*\*\*  
 none, of

IF REQUIRED, FOREIGN FILING LICENSE GRANTED  
 \*\* 12/05/2003

Foreign Priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no	STATE OR COUNTRY CA	SHEETS DRAWING 7	TOTAL CLAIMS 20	INDEPENDENT CLAIMS 2
35 USC 119 (a-d) conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no Verified and Acknowledged				
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TITLE  
 Process for etching polysilicon gates with good mask selectivity, critical dimension control, and cleanliness